

# Barentz.

SYNTHESIS SOLUTIONS

**Solutions for Semiconductor  
Fabrication & Lithography**

# Full Portfolio of Ingredient Solutions for Semiconductor Fabrication & Lithography

## What Drives Us

Driven by the powerful blend of entrepreneurship, partnership and knowledge we collaborate with our principals and customers to create and deliver 'always a better solution' on a global or local scale. We offer blending, bottling, stocking and repackaging options as well, to fit your growing needs.

## Product Categories

2-Propanol  
Acetone  
Substrate Contaminant Cleaners  
Adhesion Promoters  
Positive & Negative Photoresist  
Edge Bead Remover  
Developer Solutions  
Etchants & Acids  
Solvents  
Strippers  
CMOS & VLSI grades available

# Barentz.

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## Products Offerings

#

1827 Photoresist  
950 PMMA A5

**A**

Acetic Acid  
Acetone  
Aluminum Etch  
Ammonium Chloride  
Ammonium Fluoride  
Ammonium Hydroxide  
AZ 300T  
AZ 400K  
AZ 4330  
AZ 4620  
AZ 9260  
AZ 10XT

**B**

Bioact SC-10  
Bromine  
Buffer Oxide Etch (BOE)  
    BOE 5:1  
    BOE 7:1  
    BOE 9:1  
    BOE 30:1  
    BOE 50:1  
    BOE 500:1

**C**

Chromium Etchant  
Cobalt Sulfate  
Cyclohexanone  
Cyclopentanone

**D**

Denature Alcohol  
Dibasic Ester  
Dichloromethane  
Distilled Water  
Dowfrost

**E**

EKC 265 Remover  
EKC 270 Remover  
EKC 922 Remover  
Elba Solvent  
Ethylene Glycol

**H**

Hexamethyldisilazane  
HF Dip 10:1  
HPR504 Positive Photoresist  
Hydrazine Hydrate  
Hydrobromic Acid  
Hydrochloric Acid  
Hydrofluoric Acid  
Hydrogen Peroxide

**I**

Isobutyl Alcohol  
Isopropyl Alcohol

**L**

Lacquer Thinner  
Lenium ES  
Lor 5A

**M**

Methanol  
Methyl Alcohol  
Methyl Ethyl Keytone  
Methylene Chloride  
MF 312  
MF 319  
MF CD 26 Developer  
Microposit Developer  
Mineral Spirits  
M-Pyrol EG

**N**

Negative Resist Stripper  
Nickel Sulfate  
Nickelous Chloride  
Nitric Acid

**P**

Perchloroethylene  
PGMEA  
Phosphoric Acid  
Positive Resist Stripper  
Potassium Hydroxide  
Potassium Permanganate  
Potassium Sulfamate  
Propylene Glycol

**R**

Remover 1165

**S**

S1805 Photoresist  
S1811 G2 Photoresist  
S1813 Photoresist  
S1818 Photoresist  
SC Resist  
Sodium Chloride  
Sodium Cyanide  
Sodium Hydroxide  
Sodium Hypochlorite  
Sodium Peroxide  
Sodium Sulfate  
Solder Paste  
Sulfamic Acid  
Sulfuric Acid  
SVC 14 Positive Photo Strip

**T**

TG25E RTU Gold  
    Plating Sol  
Toluene  
Trichloroethylene  
Triethyl Phosphate  
Type 3 IC Resist

**W**

WNRD, Fuji

**X**

Xylene

**Z**

Zinc Chloride